Supplementary Information

## Efficient Perovskite Solar Cells with Negligible Hysteresis Enabled by Sol-Gel Driven Spinel Nickel Cobalt Oxide as Hole Transport Layer

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| HTL                              | Annealing temperature<br>(°C) | Sheet resistance $(\Omega/sq)$ | Conductivity<br>(S/cm) |
|----------------------------------|-------------------------------|--------------------------------|------------------------|
| NiO                              | 500                           | $> 10^{6}$                     | $> 2.5 \times 10^{-1}$ |
|                                  | 340                           | $5.27 \times 10^5$             | $4.89 \times 10^{-1}$  |
| NiCo <sub>2</sub> O <sub>4</sub> | 400                           | $7.70 \times 10^5$             | $3.25 \times 10^{-1}$  |
|                                  | 500                           | $8.37 \times 10^5$             | $2.88 \times 10^{-1}$  |

**Table S1.** Electrical conductivity of sol-gel driven NiO and NiCo2O4 annealed at different temperatures.

**Table S2.** Device parameters for *p-i-n* PSCs employing sol-gel driven NiCo<sub>2</sub>O<sub>4</sub> (340  $^{\circ}$ C) at different thickness.

| Precursor concentration | Thickness | $V_{OC}$ | $J_{SC}$    | EE   | PCE   |
|-------------------------|-----------|----------|-------------|------|-------|
| (wt%)                   | (nm)      | (V)      | $(mA/cm^2)$ | I'I' | (%)   |
| 0.5                     | 15        | 0.96     | 22.73       | 0.68 | 14.78 |
| 0.75                    | 20        | 1.05     | 22.06       | 0.74 | 17.18 |
| 1                       | 40        | 0.96     | 23.10       | 0.70 | 15.58 |

**Table S3.** Device parameters and hysteresis index (*HI*) for p-*i*-n PSCs employing sol-gel driven NiCo<sub>2</sub>O<sub>4</sub> (340 °C) at different scan rates and directions.

| Scan rate<br>(mV/s) | <i>V<sub>OC</sub></i><br>(V) |         | $J_{SC}$ (mA/cm <sup>2</sup> ) |         | FF      |         | PCE<br>(%) |         | HI    |
|---------------------|------------------------------|---------|--------------------------------|---------|---------|---------|------------|---------|-------|
|                     | Forward                      | Reverse | Forward                        | Reverse | Forward | Reverse | Forward    | Reverse |       |
| 10                  | 1.06                         | 1.06    | 22.48                          | 22.51   | 0.71    | 0.64    | 16.92      | 15.28   | 0.111 |
| 25                  | 1.06                         | 1.06    | 22.40                          | 22.36   | 0.72    | 0.65    | 17.10      | 15.41   | 0.050 |
| 50                  | 1.05                         | 1.06    | 21.96                          | 22.10   | 0.71    | 0.72    | 16.38      | 16.87   | 0.027 |
| 100                 | 1.04                         | 1.05    | 22.57                          | 22.55   | 0.74    | 0.75    | 17.37      | 17.78   | 0.022 |
| 250                 | 1.05                         | 1.06    | 22.38                          | 22.39   | 0.75    | 0.76    | 17.63      | 18.08   | 0.010 |
| 500                 | 1.06                         | 1.06    | 22.53                          | 22.50   | 0.76    | 0.76    | 18.17      | 18.13   | 0.009 |

**Table S4**. EIS fitting result for the devices with different HTLs under irradiation.

| HTL                              | R1 (Ω) | R2 (Ω) |
|----------------------------------|--------|--------|
| NiCo <sub>2</sub> O <sub>4</sub> | 42     | 153    |
| NiO                              | 56     | 252    |



Figure S1. XRD result for NiCo<sub>2</sub>O<sub>4</sub> thin films annealed at 340 °C.



Figure S2. The particle size measurement for NiOx (a) and NiCo<sub>2</sub>O<sub>4</sub> (b) thin films annealed at 340  $^{\circ}$ C.



**Figure S3.** (a) Tauc plot of sol-gel driven  $NiCo_2O_4$  thin film, (b) transmittance of sol-gel driven  $NiCo_2O_4$  at different temperatures, (c) absorbance of perovskite layer on the sol-gel driven  $NiCo_2O_4$  at different temperatures, (d) transmittance of NiO, and (e)  $NiCo_2O_4$  thin films with different thickness.



Figure S4. Molecular structure of PC<sub>61</sub>BM and Bis-C<sub>60</sub>.



**Figure S5**. J-V curves (a) and EQE spectra for *p-i-n* PSCs employing sol-gel driven NiCo<sub>2</sub>O<sub>4</sub> (340 °C) with different concentration of the precursor solution.



**Figure S6**. Work function of sol-gel driven  $NiCo_2O_4$  thin films prepared at different temperatures (a) and the schematic energy level diagram of the materials used in p-i-n PSCs.



Figure S7. Nyquist plots of the EIS measured on the devices with different HTLs under irradiation.



**Figure S8**. Degradation of  $V_{OC}$ ,  $J_{SC}$ , and FF for *p-i-n* PSCs employing sol-gel driven NiO and NiCo<sub>2</sub>O<sub>4</sub> thin films upon ambient storage with illumination, which was conducted on November 2018.



**Figure S9**. Device stability test for p-i-n PSCs employing sol-gel driven NiO and NiCo<sub>2</sub>O<sub>4</sub> thin films upon ambient storage with illumination that was conducted on March 2019.